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TABLE 1

Layer	Material	Thickness ( $\mu\text{m}$ )	Dopant	Dopant Type	Doping Density ( $\text{cm}^{-3}$ )
1	GaAs	0.01	Be	$\text{p}^+$	$1 \times 10^{19}$
2	$\text{Al}_{0.8}\text{Ga}_{0.2}\text{As}$	0.5	Be	$\text{p}^+$	$2 \times 10^{18}$
3	$\text{Al}_{0.8}\text{Ga}_{0.2}\text{As}$	1.7	Undoped		$< 10^{15}$
4	$\text{Al}_{0.8}\text{Ga}_{0.2}\text{As}$	1	Si	$\text{n}^+$	$2 \times 10^{18}$
5	GaAs	0.25	Si	$\text{n}^+$	$2 \times 10^{18}$
Substrate	$\text{n}^+$ GaAs				